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Notice of Allowability	Application No.	Applicant(s)	cant(s)	
	10/604,110	LU ET AL.		
	Examiner	Art Unit		
	Jack I. Berman	2881	•	
The MAILING DATE of this communication apper All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this app or other appropriate communication GHTS. This application is subject to	olication. If not include will be mailed in due	ed course. THIS	
1. This communication is responsive to				
2. The allowed claim(s) is/are <u>1-20</u> .				
3. \square The drawings filed on $\underline{6/26/03}$ are accepted by the Examine	er.			
 4.	been received. been received in Application No cuments have been received in this application. Set the submitted in th	national stage applicate complying with the recomplying attached of the action of the stage in the front (not the stage).	quirements OTICE OF	
 Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 6/26/03, 7/31/03 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material 	5. Notice of Informal P 6. Interview Summary Paper No./Mail Dat 8), 7. Examiner's Amendn 8. Examiner's Stateme 9. Other	(PTO-413), e nent/Comment		

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The following is an examiner's statement of reasons for allowance: While Nasser-Ghodsi et al. discloses a metrology process using a scanning electron microscope wherein a gas comprising a fluorine bearing compound such as CF₄ (see line 19 in column 5) is introduced during the irradiation of an electron beam onto a specimen in order to increase image contrast of a buried feature by etching and removing material above this feature (see lines 48-58 in column 1), the patent teaches at lines 29-42 in column 1 that this technique of introducing a reactive gas is intended to replace milling of the specimen because such milling tends to cause the contamination referred to in the "Background of Invention" section of the instant application. It would therefore go against the teachings of Nasser-Ghodsi et al. to use the reactive gas technique in addition to milling rather than instead of milling. None of the available prior art teaches to use a fluorine bearing gas to increase the contrast between an oxide layer and a nitride layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jack I. Berman whose telephone number is (571) 272-2468. The examiner can normally be reached on M-F (8:30-6:00) with every second Friday off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John R. Lee can be reached on (571) 272-2477. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jack I. Berman
Primary Examiner
Art Unit 2881

jb 6/27/04